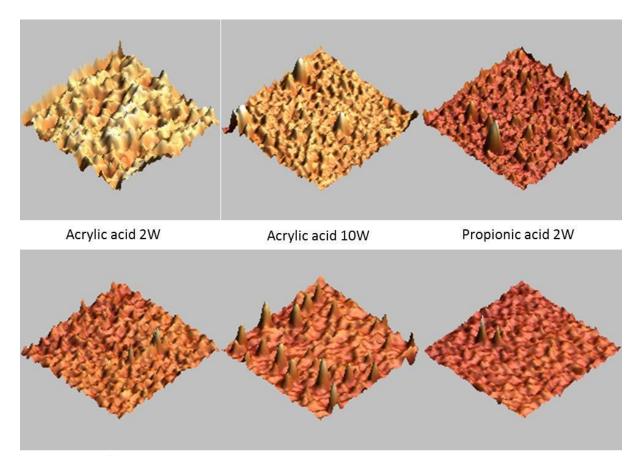
The link between mechanisms of deposition and the physicochemical properties of plasma polymer films

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Supporting Information



Octadiene 2W Octadiene 10W Hexane 2W

Figure S1	1x1 um	AFM image	s of plasma	polymer films
inguic DT.	TVT MIII	/ IIIIIIIIIIIIIIIIIIIIIIIIIIIIIIIIIIII	o piasina	polymer mins

0.45	0.38	0.38
Acrylic acid 2W	Acrylic acid 10W	Propionic acid 2W
0.39	0.46	0.31
Octadiene 2W	Octadiene 10W	Hexane 2W

Table S1. RMS roughness of plasma polymer films in nm